### PATENT APPLICATION

# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q78609

Katsura ITO, et al.

Appln. No.: 10/725,327

Group Art Unit: 1754

Confirmation No.: 2696

Examiner: NGUYEN, Cam N.

Filed: December 02, 2003

For:

PHOTOCATALYTIC POWDER, PHOTOCATALYTIC SLURRY, AND POLYMER COMPOSITION, COATING AGENT, PHOTOCATALYTIC FUNCTIONAL MOLDED ARTICLE AND PHOTOCATALYTIC FUNCTIONAL STRUCTURE USING THE

**POWDER** 

## RESPONSE UNDER 37 C.F.R. § 1.114(c)

#### MAIL STOP RCE

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated January 3, 2005 and the Advisory Action of May 28, 2005, please consider the remarks as submitted herewith on the accompanying pages.

### <u>REMARKS</u>

Claims 1 to 19 are all the claims pending in the application.

Claims 1 to 18 have been rejected under 35 U.S.C. § 102(e) as anticipated by U.S. Patent No. 6,090,736 to Taoda et al.

Applicants submit that Taoda et al do not disclose or render obvious the presently claimed invention and, accordingly, request withdrawal of this rejection.